

SYMPOSIUM PROGRAM 2013 SID INTERNATIONAL SYMPOSIUM

May 21-24, 2013 (Tuesday – Friday) Vancouver Convention Centre Vancouver, British Columbia, Canada

Session 1: Annual SID Business Meeting Tuesday, May 21, 2013/ 8:00 – 8:20 am / Ballroom C/D

- Session 2: Opening Remarks / Keynote Addresses Tuesday, May 21, 2013 / 8:20 - 10:20 am / Ballroom C/D
- 2.1: Keynote 1: Displays and Innovation: An Exciting Future Dr. Kinam Kim, President & CEO, Samsung Display Co., Chungcheongnam-do, Korea
- 2:2: Keynote 2: The Social Life of Devices
- Mr. Bill Buxton, Principal Researcher, Microsoft Research, Microsoft Corp., Redmond, WA, USA
- 2.3: Keynote 3: Exciting Developments in Oxide TFT Technology Professor John Wager, Oregon State University, Corvallis, OR, USA

Session 3: Autostereoscopic and Multi-View I (3D/Display Systems) Tuesday, May 21. 2013, / 10:50 - 11:50 am / Ballroom A Chair: Kälil Käläntär, Global Optical Solution Co-Chair: Jean-Pierre Guillou, Apple, Inc.

- 3.1: A Novel Architecture for Autostereoscopic 2D/3D Switchable Display Using Dual-Layer OLED Backlight Module Yi-Jun Wang, Shanghai Jiao Tong University, Shanghai, China
- 3.2: Application of a Flexible LCD in a High Resolution Switchable Autostereoscopic 3D Display Shiuan-Iou Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 3.3: Optimized Parallax Control of 3D Images on an Autostereoscopic Display Takefumi Hasegawa, NLT Technologies, Ltd., Kanagawa, Japan

Session 4: Oxide TFTs I (Oxide TFTs/Active-Matrix Devices) Tuesday, May 21, 2013 / 10:50 - 12:00 Noon / Ballroom B Chair: Arokia Nathan, University College London Co-Chair: Junho Song, Samsung Display Co., Ltd.

- 4.1: Invited Paper: Electronic Structure, Carrier Transport, Defects, and Impurities in Amorphous Oxide Semiconductors Toshio Kamiya, Tokyo Institute of Technology, Yokohama, Japan
- 4.2: Invited Paper: Development of High Mobility Zinc-Oxynitride TFT Yan Ye, Applied Material, Santa Clara, CA, USA
- 4.3: Invited Paper: High Mobility Oxide TFT for Large Area High Resolution AMOLED Displays Sang-Hee Park, ETRI, Daejeon, Korea
- 4.4L: Late News Paper: Modeling Current-Voltage Behavior in Oxide TFTs Combining Trap Limited Conduction with Percolation Sungsik Lee, University of Cambridge, Cambridge, UK

Session 5: LCD or OLED? (*Liquid-Crystal Technology*) Tuesday, May 21, 2013 / 10:50 - 11:50 am / Ballroom C Chair: Akihiro Mochizuki, I-CORE Technology, LLC Co-Chair: Hyun Chul Choi, LG Display Co., Ltd. 5.1: Invited Paper: LCD or OLED: Who Wins?

- 5.1. Invited Paper, ICD of OLDD. Villo Villo Villo.
 David Barnes, BizWitz, LLC, Georgetown, TX, USA
 5.2: Invited Paper; TFT LCDs as the Future Leading Role in FPDs
- 5.2. Invited Paper: AFT DOD's as the Future Deading Kole in FT Yasuhiro Ukai, Ukai Display Device Institute, Kobe, Japan
 5.3: Invited Paper: AH-IPS: Superb Display for Mobile Devices

Joun Ho Lee, LG Display Co., Ltd, Gyeonggi-do, Korea

Session 6: e-Paper I (e-Paper and Flexible Displays) Tuesday, May 21, 2013 / 10:50 am - 12:10 pm / Room 118 Chair: Makoto Omodani, Tokai University

Co-Chair: *Yong Taek Hong, Seoul National University*

6.1: Invited Paper: e-Paper System Using High Resolution Electrophoretic Display

Satoshi Nebashi, Seiko-Epson Corp., Nagano, Japan

- 6.2: Flexible Electrophoretic Display Driven by Solution Processed OTFTs Manufactured Using All Sputtered Electrodes Jung Eun Lee, LG Display R&D Center, Gyeonggi-do, Korea
- 6.3: Distinguished Paper: A 9-in. Flexible Color Electrophoretic Display with Projected-Capacitive Touch Panel and Integrated a-Si Gate Driver Yen Lai, AU Optronics Corp., Hsinchu, Taiwan, ROC

- 6.4: Invited Paper: The Effect of Touching Documents in Reading: Comparing Paper and a Touch Based Tablet Device in Intensive Proofreading Hirohito Shibata, Fuji Xerox Co., Ltd., Kanagawa, Japan
- Session 7: Plasma Display Devices (*Emissive Displays*) Tuesday, May 21, 2013 / 10:50 - 12:00 Noon / Room 202

Chair: Larry Weber, Consultant

Co-Chair: Qun Yan, Sichuan COC Display Devices Co., Ltd.

- 7.1: Invited Paper: Progress in Luminous Array Film with Plasma Tube Technology for Seamless-Tiling Super Large Area Display Terukazu Kosako, Shinoda Plasma Co., Ltd., Kobe, Japan
- **7.2:** Determination Method of Pixel Values for Combined Single-Line and Multi-Line Scanning Method for 120-Hz PDP Tomokazu Shiga, The University of Electro-Communication, Tokyo, Japan
- 7.3: Simulation Study of a Flat Panel Radiation Detector Based on Shadow Mask PDP Yan Tu, Southeast University, Nanjing, China
- 7.4L: Late News Paper: New, Thinner Phosphor Layer Fabrication Process for ACPDPs Ryuichi Murai, Panasonic AVC Networks Company, Osaka, Japan
- Session 8: Emerging Displays (*Applications*) Tuesday, May 21, 2013 / 10:50 - 11:50 am / Room 205 Chair: Jean-Noel Perbet, THALES Avionic
- Co-Chair: Adi Abileah, Planar Systems, Inc.
- 8.1: Invited Paper: Optical and System Considerations for Mobile Touch Screen Applications Steven Bathiche, Microsoft, Redmond, WA, USA
- 8.2: Semi-Transparent Inverted Quantum Dot LEDs Jin Jang, Kyung Hee University, Seoul, Korea
- 8.3: Blur-Free Transparent LCD with Hybrid Transparency Chia-Wei Kuo, AU Optronics Corp., Hsinchu, Taiwan

Session 9: Autostereoscopic and Multi-View II (3D/Display Systems) Tuesday, May 21, 2013 / 2:00 - 3:00 pm / Ballroom A Chair: Matthew Brennesholtz, Insight Media Co-Chair: Jae Hyeung Park, Chungbuk National University

- 9.1: Frontal Projection Type 3D Display with Enhanced Brightness Uniformity Byoungho Lee, Seoul National University, Seoul, Korea
- 9.2: A Wide View, High Resolution, 3D Display Using Real Time Rendering Regarding Viewer Position Yingbao Yang, Japan Display, Inc., Kanagawa, Japan
- **9.3:** Round View Display Motion-Parallax Based 3D Display with Super Wide Viewing Angle Hidefumi Takamine, Toshiba Corp., Kawasaki, Japan

Session 10: Oxide TFTs II (Oxide TFTs/Active-Matrix Devices) Tuesday, May 21, 2013 / 2:00 - 3:00 pm / Ballroom B Chair: Tohru Nishibe, Japan Display Central, Inc.

Co-Chair: Hyun Jae Kim, Yonsei University

- **10.1:** High Mobility Self-Aligned Top Gate Oxide TFT for High Resolution AMOLEDs Narihiro Morosawa, Sony Corp., Kanagawa, Japan
- **10.2:** Invited Paper: Development of Advanced Co-Planar Oxide TFT for OLED Displays Jong Uk Bae, LG Display Co., Ltd., Gyeonggi-do, Korea
- **10.3:** *Invited Paper:* High Mobility Oxide TFTs for Future LCDs Junho Song, Samsung Display Co., Ltd., Gyeonggi-do, Korea
- 10.4: Improvement in Stability of a-IGZO LCDs Chun Wei Wu, BOE Technology Group Co., Ltd., Beijing, China

Session 11: 4K x 2K Displays (*Liquid-Crystal Technology*) Tuesday, May 21, 2013 / 2:00 - 3:00 pm / Ballroom C

Chair: Shui Chih Lien, TCL Group

Co-Chair: Matthew Sousa. 3M

- 11.1: *Invited Paper*; Development of Largest 110-in. 4K x 2K 3D TFT LCD
- Chung-Yi Chiu, Shenzhen China Star Optoelectronics Technology Co., Ltd., Guangdong, China
 Invited Paper: Development of Large Sized Oxide TFT LCD TV with ADSDS Technology
- Ji Zhang , BOE Technology Group Co., Ltd., Beijing, China **11.3:** Distinguished Paper: High Transmission VA LCD with a Three Dimensionally Shaped Pixel Electrode for 4K x 2K Displays Masashi Miyakawa, Sony Corp., Kanagawa, Japan

Session 12: e-Paper II (*e-Paper and Flexible Displays*) Tuesday, May 21, 2013 / 2:00 - 3:20 pm / Room 118 Chair: *Paul Drzaic, Apple, Inc.*

Co-Chair: Nick Colaneri, Flexible Display Center

12.1: Invited Paper: Electrofluidic Imaging Films for Brighter, Faster, and Lower Cost e-Paper Jason Heinkenfeld, University of Cincinnati, Cincinnati, OH, USA

- **12.2:** Invited Paper: Electrochemical Display for Color e-Paper and Dual Mode Display Norihisa Kobayashi, Chiba University, Chiba, Japan
- 12.3: Development of Electro-Osmotic Color e-Paper Alex Henzen, IRX Innovations BV, Son en Breugel, The Netherlands
- **12.4:** Recent Development of Transparent Electrowetting Display *Kuo Lung Lo, ITRI, Chutung, Taiwan, ROC*

Session 13: Plasma Display Protective Layer (*Emissive Displays*) Tuesday, May 21, 2013 / 2:00 - 3:00 pm / Room 202

Chair: *Ryuichi Murai, Panasonic AVC Devices Development Center* **Co-Chair:** *Kyung Cheol Choi, KAIST*

- 13.1: Improvement of Luminous Efficacy by Applying Ca_xMg_{1-x}O Protecting Layer with High Xe Content Discharge Ga Qun Yan, COC Display Device Co., Wallkill, NY, USA
- 13.2: Effects of Sealing Conditions and CaO Contents on Aging Behavior of ACPDP with (Mg,Ca)O Protective Layer Yong-Seog Kim, Hong-ik University, Seoul, Korea
- **13.3:** Secondary Electron Emission of Modified MgO Surfaces in Plasma Displays Based on First Principle Yan Tu, Southeast University, Nanjing, China

Session 14: Human Enhancement and Diagnostics (Applications) Tuesday, May 21, 2013 / 2:00 - 3:20 pm / Room 205

Chair: Jyrki Kimmel, Nokia Research Center

Co-Chair: Susan Jones, Nulumina Corp.

- **14.1:** *Invited Paper:* Sonification: Multimodal and Auditory Display of Data Bruce Walker, Georgia Institute of Technology, Atlanta, GA, USA
- **14.2:** *Invited Paper:* Development of Auditory and Cross-Modal Displays for Assistive Technology Tony Stockman, Queen Mary University of London, London, UK
- **14.3:** A Novel Concept for a Blood Vessel Viewer Based on a Bidirectional OLED Microdisplay Constanze Groβmann, Fraunhofer IOF, Jena, Germany
- **14.:** Polychromatic High Frequency Steady State Visual Evoked Potentials for Brain-Display Interaction Yu-Yi Chien, National Chiao Tung University, Hsinchu, Taiwan, ROC
- Session 15: LC Technology for 3D I (3D/Liquid-Crystal Technology)
 Tuesday, May 21, 2013 / 3:40 5:00 pm / Ballroom A
 Chair: Philip Bos, Kent State University
 Co-Chair: Terry Scheffer, Motif, Inc.
 15.1: Invited Paper: High Performance Autostereoscopic 2D/3D Switchable Display Using Liquid Crystal Lens Shinichiro Oka, Japan Display, Inc., Chiba, Japan
- 15.2: Distinguished Paper: LC GRIN Lens Mode with Wide Viewing Angle for Rotatable 2D/3D Tablet Masako Kashiwagi, Toshiba Corp., Kawasaki, Japan
- 15.3: A Novel Liquid Crystal Lens for Autostereoscopic 3D Displays Sheng-Chi Liu, AU Optronics Corp., Hsinchu, Taiwan
- 15.4: Function Integrated LC GRIN Lens for Partially Switchable 2D/3D Display Ayako Takagi, Toshiba Corp., Kawasaki, Japan
- Session 16: Oxide-TFT Reliability (Oxide TFTs/Active-Matrix Devices)
- Tuesday, May 21, 2013 / 3:40 5:00 pm / Ballroom B

Chair: Yoshitaka Yamamoto, Sharp Corp.

Co-Chair: Takatoshi Tsujimura, Konica-Minolta

16.1: Negative Bias Photodegradation Mechanism in SnO TFTs

- Masashi Tsubuku, Semiconductor Energy Laboratory Co., Ltd, Kanagawa, Japan16.2:A 4.8-in. AMOLED Display Panel Driven by Stable Amorphous InZnO TFT
- Lei Wang, Guangzhou New Vision Opto-Electronic Technology Co., Ltd., Guangzhou, China 16.3: AC and DC Bias Temperature Stability of Coplanar Homojunction a-InGaZnO TFT
- Eric Yu, University of Michigan, Ann Arbor, MI, USA
 16.4: Photostability Improvement of a-InGaZnO TFTs by Introducing a Transparent UV Shielding Layer Min-Yen Tsai, National Chiao Tung University, Hsinchu, Taiwan, ROC
- Session 17: Blue Phase LCDs I (*Liquid-Crystal Technology*) Tuesday, May 21, 2013 / 3:40 - 4:30 pm / Ballroom C Chair: Shin-Tson Wu, University of Central Florida Co-Chair: Martin Schadt, MS Hightech Consulting 17.1: Invited Paper: Polymer Stabilized Blue Phase LCDs Applying Novel Groove Cell Structure
- Cheng-Yeh Tsai, AU Optronics Corp., Hsinchu, Taiwan, ROC 17.2: Low Voltage Blue Phase LCD with Red Shifted Bragg Reflection
- Jin Yan, University of Central Florida, Orlando, FL, USA 17.3L: Late News Paper: Enhancing the Contrast Ratio of Blue Phase LCDs Yifan Liu, University of Central Florida, Orlando, FL, USA

Session 18: Flexible AMOLED Displays (e-Paper and Flexible Displays) Tuesday, May 21, 2013 / 3:40 - 4:50 pm / Room 118 Chair: Ruiqing Ma, Universal Display Corp.

Co-Chair: Rashmi Rao, Apple, Inc.

- **18.1:** *Invited Paper:* Roll-to-Roll Manufacturing of Printed OLEDs Jukka Hast, Oulu, Finland
- 18.2: A 3.4-in. Flexible High Resolution Full Color Top Emitting AMOLED Display Akihiro Chida, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 18.3: Flexible Barrier Technology for Enabling Rollable AMOLED Displays and Upscaling Flexible OLED Lighting Flora Li, Holst Centre/TNO, Eindhoven, The Netherlands
- 18.4L: Late News Paper: Full Color Flexible Top-Emission AMOLED Display on Polyethylene Naphthalate (PEN) Foil with IGZO TFT Backplane

Yusuke Fukui, Panasonic Corp., Osaka, Japan

Session 19: Phosphors and Quantum Dot LEDs (*Emissive Displays*)

Tuesday, May 21, 2013 / 3:40 - 5:20 pm / Room 202

Chair: Ravi Rao, Specialty Phopshors, Inc.

Co-Chair: Masayuki Nakamoto, Shizuoka University

- **19.1:** Efficiency Enhancement of Indium-Phosphide Based Quantum Dot LEDs by Shell Thickness Tuning Jiwan Kim, Korea Electronics Technology Institute, Seongnam, Korea
- 19.2: Distinguished Paper: Characterization of Electron-Hole Pair Migration and Trapping in Rare Earth Doped YBO3 under Vacuum Ultraviolet Excitation
- Anthony Diaz, Central Washington University, Ellensburg, WA, USA
 19.3: Morphology Controlled Single Crystal ZnO Nanostructures Fabricated by a Novel Mist Chemical Vapor Deposition Chaoyang Li, Kochi University of Technology, Kami, Japan
- 19.4L: Late News Paper: Development of Stable Alkaline Earth Sulfide LED Phosphors for LCD Backlights Ravi Rao, Specialty Phosphors, Inc., Cupertino, CA, USA
- **19.5L:** Late News Paper: High Efficiency and Long Lifetime Quantum Dot LEDs for Flat Panel Display Application Paul Holloway, University of Florida, Gainesville, FL, USA
- **19.6L:** Late News Paper: How to Fabricate Much Brighter AC Electroluminescent Lamps: Optimizing the Alignment of the Emitting ZnS:Cu Phosphor Particles to the AC Field Jack Silver, Brunel University, London, UK

Session 20: LC Technology for 3D II (*3D/Liquid-Crystal Technology*) Wednesday, May 22, 2013 / 9:00 - 10:00 am / Ballroom A

Chair: Hoi-Sing Kwok, Hong Kong University of Science & Technology

Co-Chair: Allan Kmetz, Consultant

- 20.1: Color Holographic Display Based on Fast-Response Liquid Crystal Cell Yikai Su, Shanghai Jiao Tong University, Shanghai, China
- 20.2: Enlarged Viewing Angle of Integral Imaging System by Liquid Crystal Prism Chih-Wei Chen, National Chiao Tung University, Hsinchu, Taiwan, ROC
 20.3: Novel Adaptive Liquid Lens Actuated by Liquid Crystal Piston
- Su Xu, University of Central Florida, Orlando, FL

Session 21: OLED TV (Active-Matrix Devices/OLEDs) Wednesday, May 22, 2013 / 9:00 - 10:10 am / Ballroom B

Chair: Hyun Jae Kim, Yonsei University

Co-Chair: Sven Murano, Novaled AG

- **21.1:** *Invited Paper:* Technological Progress and Commercialization of AMOLED TV Chang-Ho Oh, LG Display Co., Ltd., Gyeonggi-do, Korea
- 21.2: Distinguished Paper: A 55-in. AMOLED TV with InGaZnO TFTs Using WRGB Pixel Design Woo-Jin Nam, LG Display Co., Ltd., Gyeonggi-do, Korea
- 21.3: A 65-in. Amorphous Oxide TFT AMOLED TV Using Side-by-Side and Fine Metal Mask Technology Jen-Yu Lee, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 21.4L: Late News Paper: Recent Developments in Carbon Nanotube Enabled Vertical Organic Light-Emitting Transistors for OLED Displays

Mitchell McCarthy, nVerPix, LLC, and University of Florida, Gainesville, FL, USA

Session 22: Blue Phase LCDs II (*Liquid-Crystal Technology*) Wednesday, May 22, 2013 / 9:00 - 10:20 am / Ballroom C

Chair: Xiao-Yang Huang, Ebulent Technologies Corp

Co-Chair: Kei-Hsiung Yang, National Chiao Tung University

- 22.1: Invited Paper: Low Voltage Polymer Stabilized Blue Phase Liquid Crystal Yasuhiro Haseba, JNC Petrochemical Corp., Chiba, Japan
- 22.2: Invited Paper: Liquid Crystalline Cubic Blue Phase in Photo-Responsive Bent Core Molecular System Suk-Won Choi, Kyung Hee University, Seoul, Korea
- 22.3: Polymer System Effect on Polymer Stabilized Blue Phase Liquid Crystal Jian Gang Lu, Shanghai Jiao Tong University, Shanghai, China
- 22.4: Multi-Stable LCD with Dual Frequency Reverse Mode Polymer Stabilized Cholesteric Texture Jiun-Haw Lee, National Taiwan University, Taipei, Taiwan, ROC

Session 23: Flexible TFTs (*e-Paper and Flexible Displays*) Wednesday, May 22, 2013 / 9:00 - 10:20 am / Room 118 Chair: Bruce Gnade, University of Texas at Dallas

Co-Chair: Jin Jang, Kyung Hee University

- 23.1: Invited Paper: Jet Printed TFTs and Circuits for Flexible Electronics Robert Street, Palo Alto Research Center, Palo Alto, CA, USA
- 23.2: Invited Paper: Solution Processed Metal Oxide TFTs and Circuits on Plastic by Photochemical Activation Proces Sung Kyu Park, Chung-Ang University, Seoul, Korea
- 23.3: Invited Paper: Upgrading Self-Aligned Imprint Lithography (SAIL) in Preparation for Roll-to-Roll Manufacturing of Large Sized High Performance Flexible Electronics Han-Jun Kim, Hewlett-Packard Labs, Palo Alto, CA USA
- 23.4: Delamination Effect on Flexible LTPS TFTs Ssu-Hui Lu, AU Optronics Corp., Hsinchu, Taiwan, ROC

Session 24: Novel Measurements (*Display Measurement*) Wednesday, May 22, 2013 / 9:00 - 10:20 am / Room 202 Choine Stanlage Atwasd Academic Com

Chair: Stephen Atwood, Azonix Corp.

Co-Chair: Xiao-Hua Li, Southeast University

- 24.1: Invited Paper: Photography of Display Surfaces Using Consumer Cameras: Three Regimes and Tristimulus Imagery Edward Kelley, KELTEK, Longmont, CO, USA
- 24.2: Distinguished Paper: Viewing Angle Measurements on Flexible Reflective e-Paper Displays Dirk Hertel, E Ink Corp., Cambridge, MA, USA
- 24.3: Characterization and Modeling of Light-Diffusing Sheet Yue Cui, Liquid Crystal Institute, Kent State University, Kent, OH, USA
 24.4: A Novel Measurement Method for Sparkle "Characterization"
- Ellen Kosik-Williams, Corning Incorporated, Corning, NY, USA

Session 25: Advanced LCD Electronics (*Display Electronics*) Wednesday, May 22, 2013 / 9:00 - 10:00 am / Room 205 Chair: Ya Hsiang Tai, National Chuao Tung University Co-Chair: Achin Bhowmik, Intel Corp.

- 25.1: Invited Paper: Capacitively Coupled 13.56-MHz Resonance Controlled Wireless Power Transfer System for e-Paper Modules Reiji Hattori, Kyushu University, Fukuoka, Japan
- 25.2: Invited Paper: ESD and EOS Impact During Module Assembly Processes of Display Panel Ming-Dou Ker, National Chiao-Tung University, Hsinchu, Taiwan, ROC
 25.3: Pixel Circuit with Bootstrapping Structure for Blue Phase LCDs
- Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC

Session 26: Holographic and Volumetric Displays (3D/Display Systems) Wednesday, May 22, 2013 / 10:40 - 11:40 am / Ballroom A Chair: Jean-Pierre Guillou, Apple, Inc.

Co-Chair: Masaru Suzuki, SKC Haas Display Film

- **26.1:** A Coarse Integral Holographic Display Quinn Smithwick, Disney Research, Glendale, CA, USA
- 26.2: A Two Step Wave Field Projection Method for Fast Hologram Pattern Generation Hocheon Wey, Samsung Advanced Institute of Technology, Gyeonggi-do, Korea
- 26.3: Volumetric Display System Using Multiple Mini-Projectors Yongtian Wang, Beijing Institute of Technology, Beijing, China

Session 27: OLED Displays I (OLEDs)

Wednesday, May 22, 2013 / 10:40 - 11:50 am / Ballroom B

Chair: Sven Murano, Novaled AG

Co-Chair: Yusin Lin, AU Optronics Corp.

- 27.1: A 13.3-in. CAAC IGZO FET OLED Display with Narrow Driver Area Using a Highly Efficient Deep Blue Device
- *Tsunenori Suzuki, Semiconductor Energy Laboratory Co., Ltd., Atsugi, Japan* 27.2: The Study of Picture Quality of AMOLED TV with WRGB OLED Structure.
- Jong-Kun Yoon, LG Display Co., Ltd., Gyeonggi-do, Korea 27.3L: Late News Paper: Subpixel Structured OLED Microdisplay Rigo Herold, Fraunhofer COMEDD, Dresden, Germany

Session 28: Advanced Displays (*Liquid-Crystal Technology*) Wednesday, May 22, 2013 / 10:40 am - 12:10 pm / Ballroom C

Chair: Anthony Lowe, Lambent Consultancy

Co-Chair: Cheng Chen, Apple, Inc.

- 28.1: Distinguished Student Paper: High Performance Fringe-Field Switching with a Negative Dielectric Anisotropy Liquid Crystal
- Yuan Chen, University of Central Florida, Orlando, FL, USA
 28.2: Driving Method of FFS Mode Oxide LCD for Reducing Eye Strain Ryo Hatsumi, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 28.3: A Novel Vertically Aligned IPS LCD Mode with a Charge-Shared Structure Sau-Wen Tsao, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 28.4: A Novel Liquid Crystal Mode with High Picture Quality Mei-Ju Lu, AU Optronics Corp., Hsinchu, Taiwan, ROC

- 28.5L: Late News Paper: Wide Color Gamut and Wide Viewing Angle Color Reflective LCD with Novel Anisotropic Diffusion Layer Takahiro Ishinabe, Tohoku University, Sendai, Japan
- Session 29: Flexible Barriers and Substrates (e-Paper and Flexible Displays)

Wednesday, May 22, 2013 / 10:40 - 11:40 am / Room 118

Chair: Kevin Gahagan, Corning Incorporated

Co-Chair: *Ryoichi Ishihara, Delft University of Technology*

29.1: Ultra-High Barriers for Encapsulation of Flexible Displays and Lighting Devices

- John Fahlteich, Fraunhofer Institute for Electron Beam and Plasma Technology FEP, Dresden, Germany 29.2: Atomic Layer Deposition of Al₂O₃/ZrO₂ Nanolaminate on Plastic Substrates for Flexible Displays Hyun Gi Kim, Kyung Hee University, Yongin, Korea
- 29.3: Invited Paper: The Mechanical Reliability of Flexible ALD Barrier Film Samuel Graham, Georgia Institute of Technology, Atlanta, GA, USA
- **29.4:** Invited Paper: Paper Electronics: A Challenge for the Future Rodrigo Martins, Universidade Nova de Lisboa (UNL), Caparica, Portugal

Session 30: Challenges in 3D Characterization, Motion-Blur Analysis, and Monitor Calibration (*Display Measurement*)

Wednesday, May 22, 2013 / 10:40 - 11:50 am / Room 202

Chair: Thomas Fiske, Qualcomm MEMS Technology

Co-Chair: Chuck Yin, Apple, Inc.

- **30.1:** Invited Paper: Techniques and Challenges in the Measurement of Stereoscopic Displays Adi Abileah, Planar Systems, Beaverton, OR, USA
- **30.2:** Driving Scheme Required for Blur-Free Motion of a Target Moving at 480 pps Owen Watson, Lockheed Martin Corp., Gaithersburg, MD, USA
- **30.3:** Comparison of On-Screen Display Based and ICC Profile Based Calibration for OLED Displays Wei-Chung Cheng, U.S. Food and Drug Administration, Silver Spring, MD, USA
- 30.4L: Late News Paper: A High Resolution Method for Measuring 3D Crosstalk Spatial Uniformity John Penczek, NIST, Boulder, CO, USA
- Session 31: High Speed Driver Technologies (Display Electronics)

Wednesday, May 22, 2013 / 10:40 am - 12:00 Noon / Room 205

Chair: Dick McCartney, Samsung Display Co.

Co-Chair: Taesung Kim, Apple, Inc.

- 31.1: A 3.5-Gbps/Lane Intra-Panel Interface with a PVT Robust VCO-Based CDR for UD TV Applications in 0.18-µm High Voltage CMOS Technology
- Young-Hwan Chang, Samsung Electronics Co., Ltd., Yongin, Korea 31.2: Power Efficient 5.0-in. 440-ppi Full HD a-Si TFT LCD Single Chip Driver IC
- Young-Sun Na, LG Electronics, Seoul, Korea 31.3: A 10-bit CMOS DAC with Logarithmic Time Interpolation
- Young-Chan Jang, Kumoh National Institute of Technology, Gyungbuk-do, Korea 31.4: A 3.4-Gbps/Lane Low Overhead Clock Embedded Intra-Panel Interface for High Res
- 31.4: A 3.4-Gbps/Lane Low Overhead Clock Embedded Intra-Panel Interface for High Resolution and Large Sized TFT LCDs Woon-Taek Oh, Samsung Electronics Co., Ltd., Yongin, Korea

Session 32: Light-Field Display (*3D/Display Systems*) Wednesday, May 22, 2013 / 3:30 - 4:50 pm / Ballroom A

Chair: Brian Schowengerdt, University of Washington

Co-Chair: Jae Hyeung Park, Chungbuk National University

- 32.1: Optimal Projector Configuration Design for a 300-Mpixel Light Field 3D Display Jin-Ho Lee, Samsung Institute of Advanced Technology, Gyeonggi-do, Korea
- **32.2: 360° Floating Light Field 3D Display Based on a High Frame Rate Color Projector** *Xu Liu, Zhejiang University, Hangzhou, China*
- 32.3: Light Field Approximation Using Basic Display Layer Primitives Nicola Ranieri, ETH Zurich, Zurich, Switzerland
- 32.4: A Scalable, Collaborative, Interactive Light Field Display System Michael Klug, Zebra Imaging, Inc., Austin, TX, USA
- Session 33: OLED Displays II (OLEDs)

Wednesday, May 22, 2013 / 3:30 - 4:50 pm / Ballroom B

Chair: Chihaya Adachi, Kyushu University

Co-Chair: Chishio Hosokawa, Idemitsu Kosan Co., Ltd.

- Chung-Chia Chen, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 33.2: Spatial Resolution Characteristics of OLED Displays: A Comparative Analysis of MTF for Handheld and Workstation Formats Asumi Yamazaki, U.S. Food and Drug Administration, Silver Spring, MD, USA
- **33.3L:** Late News Paper: Optimizing Nanostructures to Enhance Optical Outcoupling of OLED Microdisplays Richard Pfeifer, Fraunhofer COMEDD, Dresden, Germany
- **33.4L:** Late News Paper: High Resolution Vacuum Patterning of Organic and Metal Layers for Organic Electronic Devices Markus Burghart, VON ARDENNE Anlagentechnik GmbH, Dresden, Germany

^{33.1}L: Late News Paper: High Resolution 4.4-in. AMOLED Display with 413-ppi Real Pixel Density

Session 34: Fast Switching LCDs (*Liquid-Crystal Technology*) Wednesday, May 22, 2013 / 3:30 - 4:30 pm / Ballroom C Chair: *Philip Chen, National Chiao Tung University*

Co-Chair: Michael Wand, LC Vision, LLC

- 34.1: Novel Super Fast Response Ultra-Wide Temperature Range VA LCD Yosuke Iwata, Sharp Corp., Nara, Japan
- 34.2: Distinguished Student Paper: A Nematic LCD with Submillisecond Gray-to-Gray Response Time Daming Xu, University of Central Florida, Orlando, FL, USA
- **34.3:** Dual π-Cell Fast Response LCD for 3D Application *Philip Bos, Kent, OH, USA*

Session 70: Late News Papers: Flexible OLEDs and Printing Electronics (*e-Paper and Flexible Displays*) Wednesday, May 22, 2013 / 3:30 - 4:20 pm / Room 118 Chair: Makoto Omodani, Tokai University

Co-Chair: Rashmi Rao, Apple, Inc.

70.1L: Late-News Paper: 10.2-in. WUXGA Flexible AMOLED Display Driven by Amorphous-Oxide TFTs on Plastic Substrate

Nobuyoshi Saito, Toshiba Corp., Kawasaki, Japan

- 70.2L: Late News Paper: 14.7-in. Active Matrix PhOLED Displays on Temporary Bonded PEN Substrates with Low Temperature IGZO TFTs
- Barry O'Brien, Arizona State University, Flexible Display Center, Tempe, AZ, USA 70.3L: Late News Paper: All Wet Processable Barrier Film for Flexible OLED Displays Tomoyuki Kikuchi, Samsung Yokohama Research Institute, Yokohama, Japan
- 70.4L: Late News Paper: Flexible PIN Diode Sensor Array with InGaZnOx Transistor Michael Marr, Arizona State University, Flexible Display Center, Tempe, AZ, USA
- **70.5L:** Late News Paper: Low Temperature Curable Cu Ink and Fine Ink Jet Printed Patterning Miyako Fukuda, Asahi Glass Co., Ltd., Tokyo, Japan

Session 35: OLED Pixel and Driving (Display Electronics)

Wednesday, May 22, 2013 / 3:30 - 4:50 pm / Room 205

Chair: Hyoungsik Nam, Kyung Hee University

- Co-Chair: Seung Woo Lee, Kyung Hee University
- 35.1: High Resolution AMOLED Pixel Using Negative Feedback Structure for Improving Image Quality Oh-Kyong Kwon, Hanyang University, Seoul, Korea
- 35.2: A New Feedback Programming Architecture Compatible with 2T1C AMOLED Displays Thoma Charisouli, Lehigh University, Bethlehem, PA, USA
- 35.3: A 10-bit Linear R-String DAC Architecture for Mobile Full HD AMOLED Driver IC Ki-Duk Kim, KAIST, Daejeon, Korea
- 35.4: Programmable Pulse Width LTPS TFT Shift Register for High Resolution and High Frame Rate Active Matrix Flat Panel Display Hyoungsik Nam, Kyung Hee University, Seoul, Korea
- Session 36: Perception in 3D Display (*3D/Applied Vision/Human Factors*) Thursday, May 23, 2013 / 9:00 - 10:20 am / Ballroom A
- **Chair:** Yi-Pai Huang, National Chiao Tung University

Co-Chair: David Hoffman, Samsung Display

- **36.1:** Visual Comfort and Viewing Time of S3D Content on Mobile Device Takashi Shibata, Tokyo University of Social Welfare, Gunma, Japan
- **36.2:** Age Differences in the Use of Binocular Disparity and Pictorial Depth Cues in 3D Graphics Environment *Ken Kihara, Kagoshima University, Kagoshima, Japan*
- **36.3:** Effects of 3D Display System on Convergence and Accommodation *Takehito Kojima, Nagoya University, Nagoya, Japan*
- 36.4: Comparison between Different Rating Scales for 3D TV Kjell Brunnström, Acreo Swedish ICT AB, Kista, Sweden

Session 37: OLED Materials (OLEDs)

Thursday, May 23. 2013 / 9:00 - 10:20 am / Ballroom B

Chair: Yasunori Kijima, Sony Corp.

Co-Chair: Denis Kondakov, DuPont

- **37.1:** *Invited Paper:* Third Generation OLED by Hyper Fluorescence Chihaya Adachi, Kyushu University, Fukuoka, Japan
- 37.2: Efficiency Improvement of Fluorescent Blue Device by Molecular Orientation of Blue Dopant Hitoshi Kuma, Idemitsu Kosan Co., Ltd., Chiba, Japan
- **37.3:** Air Stable Electron Transport Materials for Low Voltage OLEDs Tobia Canzler, Novaled AG, Dresden, Germany
- **37.4:** *Invited Paper:* Molecular Triplet Emitters: From Design to Assembly and Functions Vivian Yam, The University of Hong Kong, Clear Water Bay, Hong Kong

Session 38: Film and Alignment (*Liquid-Crystal Technology*) Thursday, May 23, 2013 / 9:00 - 10:20 am / Ballroom C Chair: *Birendra Bahadur, Rockwell Collins*

Co-Chair: Gang Xu, Tianma Microelectronics

- 38.1: Invited Paper: Innovation of Optical Films Using Polymerized Discotic Materials: Past, Present, and Future Yoji Ito, FUJIFILM Corp., Tokyo, Japan
- **38.2:** Comparative Analysis of Polyimide Film Alignment Using Near Edge X-Ray Adsorption *Musun Kwak, LG Display Co., Ltd., Gyeonggi-do, Korea*
- 38.3: Fast Ferroelectric Liquid Crystal Modes Based on Photoaligning Technology Vladimir Chigrinov, Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
- **38.4:** Novel Photoalignment Layer for IPS Mode LCD Using 313-nm UV Light Kohei Goto, Nissan Chemical Industries, Ltd., Funabashi, Japan

Session 39: Touch User Experience (*Touch and Interactivity*) Thursday, May 23, 2013 / 9:00 - 10:00 am / Room 118 Chair: Steven Bathiche, Microsoft Co-Chair: Reiner Mauch, Schott AG

- **39.1:** *Invited Paper:* The Next Touch Evolution Advancing the Consumer Experience in Other Realms: Tasks and Tough Environment
- Donald Norman, Norman Neilsen Group, Fremont, CA, USA
 39.2: Invited Paper: Natural and Intuitive User Interfaces: Technologies and Applications Achintya Bhowmik, Intel Corp., Santa Clara, CA, USA
- **39.3:** Invited Paper: The Need for Speed in Touch Systems Albert Ng, Microsoft, Mountain View, CA, USA

Session 40: Automotive and Head-Up Displays (HUD) (Display Systems/Projection) Thursday, May 23, 2013 / 9:00 - 10:00 am / Room 202 Chair: Akihiro Tagaya, Keio University Co-Chair: Chang Huan Chan, National Tsing, Hua University

Co-Chair: Cheng-Huan Chen, National Tsing-Hua University

- **40.1:** *Invited Paper:* Head-Up Display for Car Navigation System Osami Utsuboya, Pioneer Corp., Saitama, Japan
- 40.2: Automotive Display Visibility Consideration Paul Weindorf, Visteon, Van Buren Twp., MI, USA
- **40.3:** High Efficiency Dual Mode Head-Up Display System for Vehicle Application *I-Hsuan Shao, National Tsing Hua University, Hsinchu, Taiwan, ROC*

Session 41: Colors and Image Quality (*Applied Vision/Human Factors*) Thursday, May 23, 2013 / 9:00 - 10:20 am / Room 205

Chair: Sakuichi Ohtsuka, Kagoshima University

Co-Chair: Miyoshi Ayama, Utsunomiya University

- **41.1:** Distinguished Paper: Viewer Preferences for Shadow, Diffuse, Specular, and Emissive Luminance Limits of High Dynamic Range Displays Scott Daly, Dolby Laboratories, Sunnyvale, CA, USA
- **41.2:** Evaluation on the Colorfulness of Displays Takehiro Nakatsue, Sony Corp., Kanagawa, Japan
- **41.3:** Evaluating the Effects of Environmental Illuminance on the Readability of e-Books *Tastsuya Koizuka, Nagoya University, Nagoya, Japan*
- **41.4:** Subjective Image Quality of Viewing Angle beyond the Color Difference Metric in FPDs Chao-Hua Wen, National Taiwan University of Science and Technology, Taipei, Taiwan, ROC

Session 42: 3D Algorithms and Driving (*3D/Display Systems*) Thursday, May 23, 2013 / 10:40 - 12:00 Noon / Ballroom A

Chair: Jean-Pierre Guillou, Apple, Inc.

Co-Chair: John Parker, Retired

- **42.1:** A Real Time 3D Multi-View Rendering from a Real Time 3D Capture Didier Doyen, Technicolor, Sévigné, France
- **42.2L:** Late-News Paper: Real Time Up-Converter from HDTV to 4K with Super High Resolution Seiichi Gohshi, Kogakuin University, Tokyo, Japan
- **42.3:** Efficient Multi-View Input Data Format for Glasses-Free 3D Display Jia-Fen Hung, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 42.4L: Late News Paper: Footprint of Scalable 3D Telecommunication System: Using Integral Light Field Display and Kinect Based Capture Yifan Peng, Zhejiang University, Hangzhou, China

Session 43: OLED Devices I (OLEDs)

Thursday, May 23, 2013 / 10:40 am - 12:00 Noon / Ballroom B

Chair: Denis Kondakov, DuPont Display

Co-Chair: Franky So, University of Florida

- **43.1:** *Invited Paper:* Demonstrating Ideal Injection Efficiency and Enabling Cost Effective Manufacturing with Solution Processed Hole Injection Layer *Mathew Mathai, Plextronics. Inc., Pittsburgh, PA, USA*
- **43.2:** Invited Paper: Light Outcoupling for OLEDs: Doubling the Efficiency while Keeping the Dark Current Low Guillaume Lecamp, Saint-Gobain Recherche, Aubervillier, France
- **43.3:** Inverted Top Emitting White OLEDs with Improved Optical and Electrical Characteristic Tobia Schwab, TU Dresden, Insitut für Angewandte Photophysik, Dresden, Germany

Session 44: Liquid Crystals with Reactive Mesogen (Liquid Crystal Technology) Thursday, May 23, 2013 / 10:40 am - 12:00 Noon / Ballroom C Chair: Jae Hoon Kim, Hanyang University

Co-Chair: Deng-Ke Yang, Kent State University

- Ameliorating the Sticking Phenomenon of the Photosensitive Alignment Layer by Using Reactive Mesogen 44.1: Tsu-Yu Ting, Chunghwa Picture Tubes, Ltd., Bade, Taiwan, ROC
- Critical Effect of Polymer Bumps in PS Vertically Aligned LCDs 44.2: Xinhui Zhong, Shenzen China Star Optoelectronics Technology Co., Ltd., Shenzen, China
- 44.3: Characterization of Intra-Molecular Energy Transfer in Reactive Mesogen Liquid Crystal Mixture Chung-Ching Hsieh, Shenzhen China Star Optoelectronics Technology Co., Ltd., Shenzhen, China
- 44.4: Development of Fast Response 4.3-in. WVGA FFS LCD Using Alignment Layer Mixed with Reactive Mesogen Jae-Hoon Kim, Hanyang University, Seoul, Korea

Session 45: Touch Integration and Controller (Touch and Interactivity) Thursday, May 23, 2013 / 10:40 - 11:40 am / Room 118

Chair: Jeff Han, Microsoft

Co-Chair: Byeong Koo Kim, LG Display Co., Ltd.

- 45.1: Distinguished Paper: 12.2-in. 1920 x RGBW x 720 IPS LCD Integrating In-Cell Touch Panel for Automotive Use Chihiro Tanaka, Japan Display, Inc., Kanagawa, Japan
- A Capacitive Touch Screen Controller IC with Noise Based Hybrid Sensing Scheme 45.2: Ki-Duk Kim, Samsung Electronics Co., Gyeonggi-do, Korea
- 45.3: High Intensity Radiated Field Effect on Projected-Capacitive Touch Screen Philippe Coni, THALES Avionics, Le Haillan, France

Session 46: OLED and Oxide TFT Manufacturing (Oxide TFTs/Display Manufacturing) Thursday, May 23, 2013 / 10:40 am - 12:10 pm / Room 202

Chair: Toshiaki Arai, Sony Corp.

Co-Chair: Tian Xiao, CBRITE, Inc.

- Invited Paper: Ink Jet Printed 17-in. AMOLED Display with Amorphous IGZO TFT Backplane 46.1: Ze Liu, BOE Technology Group Co., Ltd., Beijing, China
- 46.2: Invited Paper: Micron Patterned Deposition through Shadow Masks with High Precision Alignment for OLED and e-Paper Application
- Thomas Ambrose, Advantech US, Inc., Pittsburgh, PA, USA **Development of Source/Drain Electrodes for Amorphous IGZO TFTs** 46.3: Chengyuan Dong, National Engineering Lab for TFT-LCD Materials and Technologies, Shanghai Jiao University, Shanghai, China
- Self-Aligned Bottom Gate Amorphous IGZO TFT Using the Back Side Exposure Technique 46.4: Sang-Moo Park, LG Display Co. Ltd., Gyeonggi-do, Korea
- 46.5L: Late News Paper: Large Area Sputtered Al₂O₃ Films for High Mobility Active Matrix TFT Backplanes on **PVD Array System**

Andrea Kloeppel, Applied Materials GmbH & Co. KG, Alzenau, Germany

- Session 47: Human Factors on Lighting (Lighting/Applied Vision)
- Thursday, May 23, 2013 / 10:40 am 12:00 Noon / Room 205

Chair: Ingrid Heynderickx, Philips Research Laboratories **Co-Chair:** James Larimer, ImageMetrics, LLC

- Invited Paper: Displays as Light Sources: Resolving the Conflict between Gamut and Color Rendering 47.1: Lorne Whitehead, University of British Columbia, Vancouver, British Columbia, Canada
- Novel Measurement Method of Bright Light Contrast Ratio Based on Binocular Vision 47.2: Karlheinz Blankenbach, Pforzheim University, Pforzheim, Germany
- The Impact of Watching Television on Evening Melatonin Levels 47.3: Mariana Figueiro, Rensselaer Polytechnic Institute, Troy, NY, USA
- 47.4: Invited Paper: Opportunities with LEDs for Increasing the Visual Benefits of Lighting Mark Rea, Rensselaer Polytechnic Institute, Troy, NY, USA

Session 48: 3D Applications (*3D/Applications*)

Thursday, May 23, 2013 / 1:30 - 2:50 pm / Ballroom A

Chair: Ian Underwood, University of Edinburgh

Co-Chair: Bao-Jen Pong, Industrial Technology Research Institute

- Research on the Fringe Electric Field Effect of a Liquid Crystal Phase Modulator for Digital Holography 48.1: Qing Li, Southeast University, Nanjing, China
- Light Field Rendering of Multi-View Contents for High-Density Light Field Displays 48.2:
- J. Park, Samsung Advanced Institute of Technology, Gyeonggi-do, Korea Viewer's Eye Position Estimation Using a Single Camera 48.3:
- Seong-Hwan Ju, LG Display Co., Ltd., Gyeonggi-do, Korea Dead Zone Free 2D/3D Switchable Barrier Type 3D Display 48.4:
- Hsuan-Yi Wu, AU Optronics Corp., Hsinchu, Taiwan, ROC

Session 49: OLED Devices II (*OLEDs*) Thursday, May 23, 2013 / 1:30 - 2:40 pm / Ballroom B Chair: Tariq Ali, eMagin Corp.

Co-Chair: Michael Weaver, Universal Display Corp.

- **49.1:** *Invited Paper:* Solution Processed OLED Displays: Advantages and Challenge Shiva Prakash, DuPont Display, Santa Barbara, CA, USA
- **49.2:** A Study on Electron Injecting and Surface Modifying Layer for Transparent OLEDs Jang Hyuk Kwon, Kyung Hee University, Seoul, Korea
- **49.3:** Highly Efficient OLED Device with Device Architecture for Reducing Drive Voltage Yoshiharu Hirakata, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- **49.4L:** Late News Paper: Highly Transmissive One Sided Emission OLED Panel for Novel Lighting Application Akio Amano, Toshiba Corp., Kawasaki, Japan

Session 50: Low Power and Sensor Integrated Display (*Active Matrix Devices*) Thursday, May 23, 2013 / 1:30 - 2:30 pm / Ballroom C Chair: Kalluri Sarma, Honeywell, Inc. Co-Chair: Kenichi Takatori, NLT Technologies, Ltd.

- 50.1: Innovative 5-in. FHD and 7-in. WQXGA Displays for Next Generation Smart Phones and Tablet Toshiki Kaneko, Japan Display, Inc., Mobara, Japan
- 50.2: Adding Depth Sensing Capability to an OLED Display System Based on Coded Aperture Imaging Sungjoo Suh, Samsung Advanced Institute of Technology, Gyeonggi-do, Korea
- 50.3: Low Power High Image Quality Color Reflective LCDs Realized by Memory-in-Pixel Technology and Optical Optimization Using Newly Developed Scattering Layer Yoko Fukunaga, Japan Display, Inc., Kanagawa, Japan

Session 51: Touch Application (*Touch and Interactivity*) Thursday, May 23, 2013 / 1:30 - 2:30 pm / Room 118 Chair: John Zhong, Apple, Inc.

- Co-Chair: Bob Senior, IsiQiri Interface Technologies GmbH
- 51.1: Integrated Touch Sensing and Front Lit Device and Applications
- Ion Bita, Qualcomm MEMS Technologie, San Jose, CA, USA 51.2: Touch Mura Mechanisms and Its Suppression by Use of Cover Glass Tomohiro Ishikawa, Corning Incorporated, Corning, NY, USA
- 51.3: Pulling Force Sensing Unit for 3D Image Movement Tsun-Yi Chen, National Tsing Hua University, Hsinchu, Taiwan, ROC

Session 52: Oxide TFT Manufacturing (Oxide TFTs/Display Manufacturing) Thursday, May 23, 2013 / 1:30 - 2:50 pm / Room 202

Chair: Fang Chen Luo, AU Optronics Corp.

Co-Chair: Jerzy Kanicki, University of Michigan

- 52.1: Invited Paper: High Performance Metal Oxide TFT on Flexible Plastic Substrates Chan-Long Shieh, CBRITE, Inc., Goleta, CA, USA
- 52.2: Invited Paper: Advanced Sputtering Technologies and Targets for Oxide Semiconductor TFT Masasuke Matsudai, ULVAC, Inc., Kanagawa, Japan
- **52.3:** Development of the Back Channel Etched TFT Using C Axis Aligned Crystalline InGaZn Oxide Takuya Hirohashi, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 52.4: Distinguished Paper: Electrical Properties of Amorphous InGaZnO TFTs Prepared by Magnetron Sputtering Using Kr and Xe Gas Tetsuya Goto, Tohoku University, Sendai, Japan

Session 53: Lighting Design (*Lighting/Applications*) Thursday, May 23, 2013 / 1:30 - 2:50 pm / Room 205

Chair: Gary Jones, Nanoquantum Corp.

Co-Chair: Susan Jones, Nulumina Corp.

- 53.1: Invited Paper: Drivers in the Adoption Speed of Solid-State Lighting Coen Liedenbaum, Philips Research Laboratories, Eindhoven, The Netherlands
- **53.2:** An Optimization Design Method of an LED Freeform Lens for Uniform Circular Illumination *Zhenrong Zheng, Zhejiang University, Hangzhou, China*
- 53.3: Properties of a Field Emission Lighting Device Employing Highly Crystallized Single Wall Carbon Nanotube Toshimasa Hojo, Tohoku University, Miyagi, Japan
- 53.4: U-Shaped Daytime Running Light Using Textured TIR Lens Kuan-Yu Chen, Chilin Technology Co., Ltd., Tainan, Taiwan, ROC

Session 54: Projection Screens (*3D/Projection*) Thursday, May 23, 2013 / 3:10 - 4:30 pm / Ballroom A Chair: Sergei Yakovenko, LensVector, Inc.

Co-Chair: Alan Sobel, Flatscreen Technologies Corp.

- 54.1: Achieving High Stereo Contrast Ratio in Polarization Based 3D Front Projection Gary Sharp, RealD, Inc., Boulder, CO, USA
- 54.2: Invited Paper: High Efficiency Polarization Preserving Cinema Projection Screen Dave Coleman, RealD, Inc., Boulder, CO, USA

- 54.3: Full Color High Contrast Front Projection on a Black Emissive Screen Ted Sun, Superimaging, Fremont, CA, USA
- 54.4: Novel Transparent Emissive Display on Optically Clear Phosphor Screen Minghua Zhu, California State University, East Bay, CA, USA

Session 55: OLED Manufacturing (OLEDs)

Thursday, May 23, 2013 / 3:10 - 4:10 pm / Ballroom B

Chair: *Chin Hsin (Fred) Chen, National Chaio Tung University* **Co-Chair:** *Yasunori Kijima, Sony Corp.*

- 55.1: Invited Paper: Organic Vapor Jet MicroPrinting of OLED Displays and Lighting Panel Stephen Forrest, University of Michigan, Ann Arbor, MI, USA
- 55.2: Ink-Jet-Printed AMOLED Displays Based on IGZO TFTs: Cost Does Matter! Chih-Lei Chen, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 55.3: Development of Transparent Filling Type Desiccant for OLEDs Takahiro Niiyama, Futaba Corp., Chiba, Japan
- 55.4: Invited Paper: Development of Highly Productive In-line Vacuum Evaporation System for OLED Lighting Young Im, Sunic System, Suwon, Korea
- Session 56: TFT Application (Active Matrix Devices)

Thursday, May 23, 2013 / 3:10 - 4:30 pm / Ballroom C

Chair: James Chang, Apple, Inc.

Co-Chair: *Tohru Nishibe, Japan Display Central, Inc.*

- 56.1: Invited Paper: Development of IGZO TFT and Creation of New Devices Using IGZO TFTs Hajime Imai, Sharp Corp., Kameyama, Japan
- 56.2: Investigating IGZO TFT Performance under Gate Bias Stress with and without Light Illumination for 4K x 2K 65-in. Display
- Bo-Liang Yeh, AU Optronics Corp., Hsinchu, Taiwan, ROC
 56.3: Performance Improvement of Compensation Circuit Using p-Type SPC TFT for AMOLED Driving Jungmin Lee, LG Display Co., Ltd., Gyeonggi-do, Korea
- 56.4L: Late News Paper: 2.1-in. WXGA TFT LCDs Driven by Solution Processed Metal Oxide TFTs Liang-Yu Lin, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 56.5:L Late News Paper: All Printed Oxide TFT Arrays for High Resolution Active Matrix Displays Shinji Matsumoto, Ricoh Co., Ltd., Yokohama, Japan

Session 57: Touch Sensors, Materials, and Manufacturing (*Touch and Interactivity/Display Manufacturing*) Thursday, May 23, 2013 / 3:10 - 4:10 pm / Room 118

Chair: Willem Den Boer, Guardian Industries Corp.

Co-Chair: Lauren Palmateer, Subtle Energy Design

57.1: WITHDRAWN

- **57.2:** Transparent Conductive Coatings Made by Electrochemical and Physicochemical Method A Smirnov, Belarusian State University of Informatics and Radioelectronic, Minsk, Belaru
- 57.3: WITHDRAWN
- 57.4: Ink Jet Printed Silver Ring Coating to Replace ITO Robert Even, ClearJet, Yokneam, Israel
- 57.5L: Late News Paper: Flexible Transparent Conductors and Touch Sensors for High Contrast Displays Erkki Soininen, Canatu Oy, Helsinki, Finland
- 57.6L: Late News Paper: Touch Sensor ITO Thin Films Deposited Using Rotary Sputtering Technology: Comparison of Coating Properties and Cost for DC vs. MF-AC Deposition. Paul Lippen, Unicore Thin Film Products AG, Balzer, Liechtnstein

Session 58: Advanced Substrates and Manufacturing on Flex (*Display Manufacturing/e-Paper and Flexible Displays*)

Thursday, May 23, 2013 / 3:10 - 4:30 pm / Room 202

Chair: Greg Gibson, FAS Holdings Group

Co-Chair: Ryoichi Ishihara, Delft University of Technology

- 58.1: Invited Paper: Advanced Glass Substrate for the Enhancement of OLED Lighting Outcoupling Efficiency Nobuhiro Nakamura, Asahi Glass Co., Ltd., Yokohama, Japan
- 58.2: Distinguished Paper: Roll-to-Roll Process on Ultra Thin Flexible Glass for Manufacturing a Multi Touch Sensor Panel Chia-Sheng Huang, ITRI, Hsinchu, Taiwan, ROC
- 58.3: Reliability and Barrier Layer Dependency of Flexible 2D/3D- witchable Liquid Crystal Cell Pin-Hsiang Chiu, AU Optronics Corp., Hsinchu, Taiwan, ROC
- 58.4: A Novel Handling Method for Ultra-Thin Flexible Glass Substrates for Thin and Flexible Displays Ru-De Chen, ITRI, Hsinchu, Taiwan, ROC

Session 59: Novel Backlighting System (*Display Systems*) Thursday, May 23, 2013 / 3:10 - 4:10 pm / Room 205 Chair: Masaru Suzuki, SKC Haas Display Film Co-Chair: Akihiro Tagaya, Keio University

- **59.1:** A Backlight System with a Phosphor Sheet to Provide 90% NTSC Gamut with Improved Optical Efficiency *Yasushi Ito, Dexerials Corp., Kanuma, Japan*
- 59.2: A Novel LED Backlight System with Tilted Cylindrical Surfaces on the Light Guide Plate Kazutada Takaira, Mitsubishi Electric Corp., Kumamoto, Japan

- 59.3: Compact LED Pixelized Backlight for LCDs Chin Sher, National Tsing Hua University, Hsinchu, Taiwan, ROC
- 59.4: WITHDRAWN

Session 60: Projection Light Source (Projection)
Friday, May 24, 2013 / 9:00 - 10:30 am / Ballroom A
Chair: David Eccles, Rockwell Collins
Co-Chair: Fujio Okumura, NEC Corp.
60.1: Integrated RGB Laser Flat Package Module Using Si Platform Technology Masafumi Ide, Citizen Holdings Co., Ltd., Tokorozawa, Japan

- 60.2: Distinguished Paper: A 30-W Pure Blue Emission with NUV Laser Diode Pumped Phosphor for High-Brightness Projector Kiyoshi Morimoto, Panasonic Industrial Devices Co., Kyoto, Japan
- **60.3:** A 6-W Multi-Beam Green Laser for Companion Laser Projector Yi Gan, McMaster University, Hamilton, Ontario, Canada
- **60.4:** A Novel Full Color 3LED Projection System Using R-G-B LEDs on Silicon (LEDoS) Microdisplay Wing Cheung Chong, Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
- Session 61: OLED Lighting I (*Lighting/OLEDs*)
- Friday, May 24, 2013 / 9:00 10:20 am / Ballroom B Chair: Franky So, University of Florida Co-Chair: Mike Lu, Acuity Brands Lighting 61.1: Invited Paper: 80-Im/W White OLEDs for Solid State Lighting
- Jaemin Moon, LG Chem, Daejeon, Korea
- 61.2: Phosphorescent Stacked OLEDs for Warm White Lighting Applications Xin Xu, Universal Display Corp., Ewing, NY, USA
- 61.3: High Performance OLEDs on Graphene Electrode and Thin c-Si TFT for Flexible Display and Lighting Ning Li, IBM T. J. Watson Research Center, Yorktown Heights, NY, USA
- 61.4: Bottom Emitting Large Area Stacked White OLED with Silver Nanowire Network as Transparent Anode Florian Pschenitzka, Cambrios Technologies Corp., Sunnyvale, CA, USA
- 61.5L: Late News Paper: Highly Efficient White OLEDs with Single Solution Processed Emitting Layer Consisting of Three Kinds of Dopant
 - Hirotaka Sakuma, Hitachi Research Laboratory, Ibaraki, Japan

Session 62: TFTs for Mobile Displays (Active Matrix Devices)

Friday, May 24, 2013 / 9:00 - 10:20 am / Ballroom C

Chair: Kenichi Takatori, NLT Technologies, Ltd.

Co-Chair: Yoshitaka Yamamoto, Sharp Corp.

- 62.1: Invited Paper: The Joys of Being Digital: Low Power Mobile Multimedia Display Richard Payne, Pixtronix, Inc., Andover, MA, USA
- 62.2: Invited Paper: Bridged Grain Poly-Si TFT Hoi-Sing Kwok, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
- 62.3: Six-Terminal OLED Display Using Low Temperature Single Crystal Silicon (LTSS) Technology Masashi Fujita, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 62.4: High Performance Low Temperature Polycrystalline Silicon TFTs with Submicron-Dot-Array Doped Active Channel Meng Zhang, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
- Session 63: Mechanical Reliability Testing for Displays (*Display Manufacturing*) Friday, May 24, 2013 / 9:00 - 10:10 am / Room 202

Chair: Bradley Bowden, Corning Incorporated

Co-Chair: Don Carkner, Research In Motion

- **63.1:** Biaxial Stress in Thin Glass during Ring-on-Ring Testing with Large Deflection Suresh Gulati, Corning Incorporated, Corning, NY, USA
- **63.2:** A Study of the Static Push Test to Define Tensile Failure Stress for Rectangle Glass *Yu-Chen Liu, G-Tech Optoelectronics Corp., Miaoli, Taiwan, ROC*
- 63.3: Best Practices in Strength Testing of LCD Glass K. Hemanth Vepakomma, Corning Incorporated, Corning, NY, USA
- 63.4L: New Technology for Thinner Cover Glass Substrates: Improvement of Surface Strength by Polishing after Chemical Strengthening Hiroyuki Ohkawa, Asahi Glass Co., Ltd., Kanagawa, Japan

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Session 64: Near-to-Eye, Transparent, and Floating Displays (Display Systems)
Friday, May 24, 2013 / 9:00 - 10:00 am / Room 205
Chair: Bill Cumming, Qualcomm MEMS Technology
Co-Chair: W. Hendrick, Rockwell Collins Optronic
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- 64.1: High Efficiency Waveguide Display System with Achromatic Volume Hologram and a Prism In-Coupler Juan Liu, Beijing Institute of Technology, Beijing, China
- 64.2: Objective LC lens Array for a Near-to-Eye Display Sergiy Valyukh, IFM, Linkoping University, Linkoping, Sweden
- 64.3L: Late News Paper: Aerial Imaging by Retro-Reflection (AIRR)

Hirotsugu Yamamoto, University of Tokushima, Tokushima, Japan Session 65: Projection Display Components (*Projection*)

Friday, May 24, 2013 / 10:40 - 12:00 Noon / Ballroom A

Chair: Frederic Kahn, Kahn International, Inc.

- Co-Chair: Ming Hsien Wu, Hamamatsu Corp
- 65.1: A Vertically Aligned LCOS with Submillisecond Response Time for Color-Field-Sequential Projection Display Yuan Chen, University of Central Florida, Orlando, FL, USA
- 65.2: Blue Phase Liquid Crystals for Color Field Sequential Projection Displays Linghui Rao, University of Central Florida, Orlando, FL, USA
- 65.3: Phase-Modulation LcoS Display System with Off-Axis LED Reconstruction Light Li-Yuan Liao, National Tsing Hua University, Hsinchum Taiwan, ROC
- **65.4:** Speckle Suppression by Limited Phase Range in Laser Projection System Yan-Shuo Chang, National Taiwan University, Taipei, Taiwan, ROC

Session 66: OLED Lighting II (Lighting/OLEDs)

Friday, May 24, 2013 / 10:40 - 12:00 Noon / Ballroom B

Chair: Michael Weaver, Universal Display Corp.

Co-Chair: *Chin Hsin (Fred) Chen, National Chaio Tung University*

- 66.1: Invited Paper: Outcoupling Efficiency Enhancement Strategies in OLED Lighting Panel Min-Hao Lu, Acuity Brands Lighting, Berkeley, CA, USA
- 66.2: Invited Paper: Highly Efficient White OLEDs with Over 100-Im/W for General Lighting Kazuyuki Yamae, Panasonic Eco Solutions Company, Osaka, Japan
- 66.3: Highly Improved Light Out-Coupling of OLEDs by Utilizing a Simple and Easy Process Based on a Nano-Scale Random Light Extraction Structure Young Wook Park, Korea University, Seoul, Korea
- 66.4: Large Sized Flexible Display with Highly Efficient OLED Nobuharu Ohsawa, Advanced Film Device, Inc., Tochigi, Japan

Session 67: TFT Driver Circuit (*Active-Matrix Devices*) Friday, May 24, 2013 / 10:40 am - 12:00 Noon / Ballroom C

Chair: Roger Stewart, Sourland Mountain Associates

Co-Chair: Norbert Fruehauf, University of Stuttgart

- 67.1: Distinguished Student Paper: A 40-μm-pitch IGZO TFT Gate Driver for High Resolution Rollable AMOLED Displays Jin Jang, Kyung Hee University, Seoul, Korea
- 67.2: Novel Driving Method to Compensate RC Delays in Ultra-Large Sized and High Resolution LCDs Seung-Woo Lee, Kyung Hee University, Seoul, Korea
- 67.3: New Driving Method for Reducing Eye Strain Technology (REST) in Displaying Still Images Using C Axis Aligned Crystalline IGZO LCDs Hiroyuki Miyake, Semiconductor Energy Laboratory Co., Ltd., Kanagawa, Japan
- 67.4: Compensating Threshold Voltage Circuit in the Transient State for AMOLED Displays Collocated with Uni-Type GOA Driving
 67.4: Compensating Threshold Voltage Circuit in the Transient State for AMOLED Displays Collocated with Uni-Type GOA Driving

Shih-Song Cheng, AU Optronics Corp., Hsinchu, Taiwan, ROC

Session 68: Advances in Materials for Manufacturing (Display Manufacturing)

Friday, May 24, 2013 / 10:40 am - 12:00 Noon / Room 202

Chair: Ion Bita, Qualcomm MEMS Technologies

Co-Chair: Elliott Schlam, Elliott Schlam Associates

- **68.1:** Invited Paper: Quantum Dot Manufacturing Requirements for the High Volume LCD Market Seth Coe-Sullivan, OD Vision, Inc., Lexington, MA, USA
- 68.2: Invited Paper: Development of Novel Optical Bonding Process and Materials for Flat Panel Display Modules Kozaburo Hayashi, Dexerials Corp., Tochigi, Japan
- **68.3:** Liquid Optically Clear Adhesives for Next Generation Display Applications Daniel Lu, Henkel China, Shanghai, China
- 68.4: Minimizing the Impact of Bonding-Induced Defect Grace Yeh, DuPont, Taoyuan, Taiwan, ROC

Session 69: Energy Efficient Displays (*Display Systems/Display Electronics*) Friday, May 24, 2013 / 10:40 am - 12:00 Noon / Room 205 Chair: Wei Chen, Apple, Inc.

- Co-Chair: Haruhiko Okumura, Toshiba Corp.
- **69.1:** Image Quality Assessment of Ultra-High Resolution Mobile Display Utilizing New RGBW Method Akira Sakaigawa, Japan Display, Inc., Ebina, Japan
- **69.2:** Compact Color Filter and Polarizer Based on Nanowire Grating for Energy Efficient Displays *Zhicheng Ye, Shanghai Jiao Tong University, Shanghai, China*
- **69.3:** Balancing Luminance Boosting and Color Breakup Reduction for a Color Sequential Display Martin Hammer, TP Vision, Eindhoven, The Netherlands
- 69.4: Invited Paper: Extending Battery Life of Ultrabook through Use of Panel Self-Refresh Technology Kamal Shah, Intel Corp., Hillsboro, OR, USA

Poster Session

Thursday, May 23, 2013 / 4:00 - 7:00 pm / West Exhibit Hall B

3D

- P.1: Distinguished Student Poster Paper: Submillisecond Response Time Liquid Crystal Cylindrical Microlens Array for 3D Display Jie Sun, University of Central Florida, Orlando, FL, USA
- P.2: New Approach of Flexible e-Paper with Single Particles Seung Yong Jeong, Korean Institute of Industrial Technology, Cheonan, Kore

Active-Matrix Devices

- P.3: 3D Stacked Complementary TFT Devices Using n-Type a-IGZO and p-Type F8T2 TFTs: Operation Confirmation of NOT and NAND Logic Circuits Mutsumi Kimura, Ryukoku University, Otsu, Japan P.4: WITHDRAWN Highly Uniform Solid Phase Crystallized Bridged-Grain Poly-Si TFT P.5: Wei Zhou, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong P.6: An Integrated a-Si:H Gate Driver Circuit Design for Large Sized TFT LCD Applications Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC P.7: New Pixel Structure with High Gray-to-Gray Response Time for Large Sized and High Resolution AMOLED TVs. Joong-Sun Yoon, LG Display Co., Ltd., Gyeonggi-do, Korea Trap States in Amorphous-ITZO TFTs Analyzed Using the Dependence on Channel Thicknes P.8: Mutsumi Kimura, Ryukoku University, Otsu, Japan **P.9**: Power Saving Sunlight Readable TFT LCD Yao-Dong Ma, MacroDisplay Inc., Richardson, TX, USA WITHDRAWN P.10: P.11: Recognition of Existence of n-Type IGZO Layer in CAAC IGZO Film under a Source and Drain Electrode Made of Tungsten Ryo Tokumaru, Kanagawa, Japan P.12: Development of Novel Post-Annealing Process for Flexible Oxide TFTs Po-Tsun Liu, National Chiao Tung University, Hsinchu, Taiwan, ROC P.13: Rollable a-IGZO TFTs with Nanocomposite Dielectric on PEN Substrate Zingway Pei, National Chung Hsing University, Taichung, Taiwan, ROC P.14: Distinguished Poster Paper: Separate Extraction Technique of Intrinsic Donor and Acceptor Like Density of States over Full Energy Range Sub-Bandgap in Amorphous Oxide Semiconductor TFTs by Using One Shot Monochromatic Photonic Capacitance-Voltage Characteristic Dong Kim, Kookmin University, Seoul, Korea Influence of Photo-Thermal Pre-Treatment on Electrical Charateristics and Reliability of ZnSnO TFTs P.15: Ting-Chang Chang, National Sun Yat-Sen University, Kaohsiung, Taiwan, ROC Dynamic Supply Voltage Scaling of Pixel Circuits for Static Power Reduction in AMOLED Displays P.16: Xiaojun Guo, Shanghai Jiao Tong University, Shanghai, China Integration of Solution Processed Oxide TFTs with Normal Structure OLEDs for Low Voltage Operation P.17: **Top Emitting AMOLED Display** Xiaojun Guo, Shanghai Jiao Tong University, Shanghai, China Effects of Interface and Bulk States on the Stability of Amorphous-InGaZnO TFTs under Gate Bias and Temperature Stress P.18: Runze Zhan, Shanghai Jiao Tong University, Shanghai, China Density-of-States Based Device Circuit Co-Design Platform for Solution Processed Organic Integrated Circuit P.19: Dae Kim, Kookmin University, Seoul, Korea P.20: Transfer Characteristic-Based Electro-Optical Technique for Characterization of Carrier Lifetimes with Associated Physical Mechanisms in Polymer-Based Organic TFTs Dong Kim, Kookmin University, Seoul, Korea P.21: High Input Impedance Active Pixel Sensing Circuit with Threshold Voltage Compensation Implemented by **Dual Gate IGZO TFTs** Lu-Sheng Chou, National Chiao Tung University, Hsinchu, Taiwan Improving Switching Characteristics of Amorphous InGaZnO₄ TFTs by Dual Gate Driving P.22: Jin Jang, Kyung Hee University, Seoul, Korea Nano-Si Optical Pixel Sensor Array Using TFT Technology as Image Scan/Fingerprint Panel P.23: An-Thung Cho, AU Optronic Corp., Hsinchu, Taiwan, ROC P.157L:Late News Poster: Characterization of Asymmetrical Negative Bias Stress Effect on the Density of States and Parasitic Resistances in a-IGZO TFTs Dong Kim, Kookmin University, Seoul, Korea **Applied Vision** P.24: **Relationship between Recognition of Illumination and Depth Perception** Hiroyuki Kaji, Utsunomiya University, Utsunomiya, Japan P.25: The Effect of Environmental Illumination and Screen Brightness on Accommodation and Convergence Yuki Okada, Nagoya University, Nagoya, Japan
- P.26: Constant vs. Non-Constant Luminance Video Signals for UHDTV Seo Young Choi, SAIT, Yongin, Korea
- **P.27: Effect of Blue Primary Color on Preference and Colorfulness of Display** Seung Hyun Kim, LG Display Co., Ltd., Gyeonggi-do, Korea

- P.28: Hue Blending Method: Improved Red-Green Color Segregation Capability for Dichromacy Support Sakuichi Ohtsuka, Kagoshima University, Kagoshima, Japan
- P.29: Distinguished Poster Paper: Perception of Sparkle in Anti-Glare Display Screen Jame Ferwerda, Rochester Institute of Technology, Rochester, NY, USA
- **P.30:** Effect of the Correlated Color Temperature of Light on Overhead Glare in Office Environment Yan Tu, Southeast University, Nanjing, China
- P.134L:Late News Poster: Resolution Limits for Smartphones: Video Playback Lee Spencer, Sharp Devices Europe, Oxford, UK

Display Electronics

- **P.31:** Image Compression for Color Sequential LCOS with Decompression at the Retina Andrew Russell, Syndiant, Inc., Dallas, TX, USA
- P.32: A New a-IGZO AMOLED Pixel Circuit Design to Improve the OLED Luminance Degradation in 3D Display Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC
- P.33: Homogeneous Backlight Distribution Algorithm for SCC Local Dimming Edge-Lit LCD Tobia Jung, Saarland University, Saarbruecken, Germany
- **P.34:** A Video Signal Coding Method Based on an Absolute Color Space for Saving Bit Depth Senfar Wen, Yuan Ze University, Chung-Li, Taiwan, ROC
- P.35: Charge Recycling Match Technique for Low Power Display Column Driver Ke-Horng Chen, National Chiao Tung University, Hsinchu, Taiwan, ROC

Display Manufacturing

- **P.36:** Analysis of Rubbing Mura in Fringe Field Switching LCD Wei Zhang, BOE Optoelectronics Technology Co., Ltd., Beijing, China
- P.37: Novel Gray-Toneless Technology for Mask Reduction in High Aperture FFS Mode Seung-Jin Choi, BOE Technology Group Co., Ltd., Being, China
- P.38: Estimate of the Distribution of Contrast Ratio in Optically Compensated IPS Mode Using the Response Surface Method Koji Yonemura, Mitsubishi Electric Corp., Kumamoto, Japan
- P.39: Study of Uncured Sealant Contamination of Liquid Crystal in One Drop Filling Process for TFT LCDs Ang Xiao, BOE Optoelectronics Technology Co., Ltd., Beijing, China
- P.40: Encapsulated Flexible OLEDs: Progress toward a Simple and Cost Effective Contact Printing Technique Byeong-Kwon Ju, Korea University, Seoul, Korea
- P.41: Display Component Quality and Process Control with Advanced Automated Optical Inspection Jochen Koenig, Dr. Schenk Inspection Systems, Woodbury, MN, USA
- P.149L: Late News Poster: Behavior of OLED Panel During Four Point Bending Tzu-Chi Tseng, AU Optronics Corp., Hsinchu, Taiwan, ROC
- P.154L: Late News Poster: Establishment of Evaluation Method of Surface Fracture mode with Front-Side Origin for Cover Glass
 - Aya Nakagawa, Asahi Glass Co., Ltd., Kanagawa, Japan

Display Measurement

- P.42: Estimation and Evaluation of Image Sticking on OLED Devices Kyongho Lim, LG Display Co., Ltd., Gyeonggi-do, Korea
- P.43: Model Development for Cell Gap Induced Mura to Improve Quality of Glass Substrates to Display Manufacturers Michal Mlejnek, Corning Incorporated, Corning, NY, USA
- P.44: Display Aspect Simulation Using Measured Emissive and Reflective Display Imperfection Pierre Boher, ELDIM, Herouville, France
- P.45: The Study of LCD Panel Touch Mura John Liang, Corning Incorporated, Corning, NY, USA

Display Systems

- P.46: Enhanced Single Viewing Zone Integral Imaging Display Based on Medium Packing Technique *Qiong-Hua Wang, Sichuan University, Chengdu, China*
- P.47: Integral Imaging Display Based on Space Multiplexed Elemental Image Array *Qiong-Hua Wang, Sichuan University, Chengdu, China*
- P.48: Flat Panel Autostereoscopic Display with Wide Viewing Zone Using Time Division Multiplexing Backlight Shuta Ishizuka, University of Tsukuba, Tsukuba, Japan
- P.49: Light Diffusing Films Using Two Step UV Irradiation for Various Displays Kentaro Kusama, LINTEC Corp., Warabi, Japan
- **P.50:** Design of a Novel Hybrid Light Guide Plate for Viewing-Angle Switchable Backlight Module Jui Pan, National Chiao Tung University, Tainan, Taiwan, ROC
- P.51: Local Gamma Adjustment for High Frame Rate LCDs Hyun-Dae Lee, Samsung Display Co., Gyeonggi-do, Korea
- P.52: A Colorful Holographic Display System with Enlarged Viewing Zone Using Multiplex SLM Juan Liu, Beijing Institute of Technology, Beijing, China
- P.53: Low Dynamic Crosstalk in Scanning Liquid Crystal Prism Type 3D Display
- Jian Gang Lu, Shanghai Jiao Tong University, Shanghai, China
- P.54: Light Field Integral Display Using LCD and Eye Tracking Technique Han Wang, Zhejiang University, Hangzhou, China
- P.55: Study of Optimal Viewing Distance in an Autostereoscopic 3D (AS3D) Display Hsu-Wan Hsuan, National Taiwan University, Taipei, Taiwan
- **P.56:** X-Shaped Pixel Alignment in Large Scale Image Display System Satoshi Yamanaka, Mitsubishi Electric Corp., Kyoto, Japan
- P.57: Transmissive and Reflective Dual Operational Mode Display Device Ju-Ai Ruan, NOVA MEMS Display, Plano, TX, USA

P.147: Adaptive Anisotropic Diffusion for Depth Map Enhancement in 3D Video Coding Ilsoon Lim, Samsung Advanced Institute of Technology, Gyeonggi-do, Korea

P.148L: Late News Poster: 3D Integral Imaging Display System Using Eye Tracking Method Yiying Pu, TCL Corporate Research, Shenzhan, Guangdong, China

Emissive Displays

- P.58: Quantitative Assessment of Host-to-Activator Energy Transfer Efficiency of Multiple d-Orbital Trap States for Microcrystalline YBO₃:Tb³⁺
- Max Wallace, Central Washington University, Ellensburg, WA, USA
 P.59: New Synthesis of Novel Phosphor for LED Technology: Synthesizing Sr₃Y₂(BO₃)₄:Eu²⁺ from Strontium Borate Precursor Troy Kilburn, Central Washington University, Ellensburg, WA, USA

e-Paper and Flexible Displays

Flexible TFTs

- P.60: Thermally Stable Organic Semiconductor for Solution Processed Field Effect Transistors with High Mobilitie Takashi Fukuda, Tosoh Corp., Yokkaichi, Japan
- P.61: Negative Mold Transfer-Patterned Conductive Polymer Electrode for Flexible OLED Displays Byeong-Kwon Ju, Korea University, Seoul, Korea
- P.62: Effects of Amorphous-InGaZnO TFTs with Various Buffer Layers on a Polyimide Substrate under Negative Bias Temperature Stress
- Jin-Seong Park, Dankook University, Cheonan, Korea P.63: Low Temperature Oxide TFTs on Plastic Films for Flexible Display Application Wei-Ting Lin, AU Optronic Corp., Hsinchu, Taiwan, ROC
- P.64: WITHDRAWN
- P.65: The Effect of Surface Polarity of Gate Dielectric Buffer Layer on Operational Stability of Organic TFTs Changhee Lee, Seoul National University, Seoul, Korea

e-Paper

- P.66: An Electrowetting Light Valve Using ODF Assembly Process
- In-cha Hsieh, National Chung Hsing University, Taichung, Taiwan, ROC P.67: Reflective Color Displays Using Photonic Crystal
- Zhenyue Luo, University of Central Florida, Orlando, FL, USA
- P.68: Reflective Interferometric Modulator Display with Temporal Color Modulation Ji Zhong, Jiaxing Unipel Display Technologies, Ltd., Zhejiang, China
- P.69: Large Area Seamlessly Tiled Flexible eBoard
- Erica Montbach, Kent Display, Kent, OH, USA
- P.70: Durability and Reliability of an eWriter
- Clinton Braganza, Kent Display, Kent, OH, USA
- P.135L: Late News Poster: Development of Novel Cell Design for Flexible e-Paper Using Single Type Particle Sangkug Lee, Korea Institute of Industrial Technology (KITECH), Cheonan-do, Korea
- P.136L: Late News Poster: Using Independent Component Analysis for Colorant Estimation in Electrophoretic Displays Yen-Hsing Lu, National Chiao Tung University, Hsinchu, Taiwan, ROC
- P.150L: Late-News Poster: Conformal Display Huan Yang, ITRI, Hsinchu, Taiwan, ROC

Lighting Applications

- P.71: High Efficiency and High Uniformity Modularized Street Lamp Light Engine with a Single LED Source Kuan-Yu Chen, Chilin Technology Co., Ltd., Tainan, Taiwan, ROC
- P.72: Glass Based Color Conversion Multilayer for White LEDs and Its Angular Color Performance
- Li-Yin Chen, National Sun Yat-sen University, Kaohsiung, Taiwan, ROC
- P.73: WITHDRAWN

Liquid-Crystal Technology

Blue Phase

- P.74: Polymer Stabilized Double Twist Cylinders of Blue Phase Liquid Crystal for Reduced **Hysteresis and Operating Voltage** Seung Hee Lee, Nano-Science and Engineering, Jeonju, Korea P.75: Temperature Dependence of Dielectric and Electro-Optical Properties and Disordered Structure in Polymer Stabilized Blue Phases at Low Temperature Gihwan Lim, Kyushu University, Kasuga, Japan Threshold Temperature Effect on Phase Transition of Blue Phase Liquid Crystal P.76: Jian Gang Lu, Shanghai Jiao Tong University, Shanghai, China P.77: High Transmittance Blue Phase LCD with a Floating Electrode Yifan Liu, University of Central Florida, Orlando, FL, USA P.78: A Tunable Microlens Using Two Blue Phase Liquid Crystal Layers with Different Kerr Constant Yan Li, University of Central Florida, Orlando, FL, USA P.79: WITHDRAWN
- *Tsung-Hsien Lin, National Sun Yat-Sen University, Kaoshiung, Taiwan, ROC* P.80: Analysis of Polymer Network Structure of Polymer Stabilized Blue Phase
- Musun Kwak, LG Display Co., Ltd., Gyeonggi-do, Korea
- **P.81:** A Time Multiplexed Dual View Display Using Blue Phase Liquid Crystal *Qiong-Hua Wang, Sichuan University, Chengdu, China*

P.82: Entire Spectrum Measurement of Kerr Constant and Birefringence Dispersion in a Polymer Stabilized Blue Phase Liquid Crystal Composite

Hongqing Cui, infoVision Optoelectronics (Kunshan) Co., Ltd., Kunshan, China P.137L:Late News Poster: Polymer Dispersed Blue Phase Liquid Crystal Emine Kemiklioglu, Kent State University, Liquid Crystal Institute, Kent, OH, USA

Fast Switching

- P.83: Electrically Suppressed Helix Ferroelectric LC Field Sequential Color Display Abhishek Srivastava, The Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong
 P.84: Increasing the Light Modulation Frequency Due to the Increase in FLC Viscosity Igor Kompanet, P. N. Lebedev Physical Institute, Moscow, Russia
- P.85: Fast Switching of an IPS Cell at Low Temperature by Forming Polymer Network Tae-Hoon Yoon, Pusan National University, Busan, Korea
- P.86: A Novel Bistable LCD Having Memory Display Mode and High Speed Switching Mode Taiju Takahashi, Kogakuin University, Tokyo, Japan
- **P.87:** The Study of Improvements in the Flatness of an LCD Panel Using an Advanced Polarizer Seong Han Hwang, LG Display Co., Ltd., Gyeonggi-do, Korea
- P.88: A Novel Design of a Polarizer with a Parallel Absorb Axis Chih-Tsung Kang, Shenzhen China Star Optoelectronics Technology Co., Shenzhen, Guangdong, China
- P.156L:Late News Poster: Real Time Dynamic Color Holographic Display Using a Super-Fast-Response Liquid Crystal Thin Film Hongyue Gao, Virginia Tech, Blacksburg, VA, USA

LCD Optical Characteristics

- P.89: Direct Measurements of Asymmetric Pretilt Angles of Optically Compensated Bend (OCB) Nematic Liquid Crystal Cell Sheng-Ya Wang, National Chiao Tung University, Tainan, Taiwan, ROC
- **P.90:** Optical Properties of LC Cells with Hybrid Orientation and Negative Birefringence V Belyaev, Moscow Region State University, Moscow, Russia
- P.91: Adobe RGB LCD Monitor with Three Primary Colors by Using Deep-Green Color Filter Technology Seung Hoon Ji, LG Display Co., Ltd., Gyeonggi-do, Korea
- **P.92:** Characterization of Complex Liquid Crystal Polarization Gratings at Oblique Incidence Using Extended Jones Matrix Method Li Tan, Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong

Polymer Dispersed Liquid Crystal

- P.93: Optically Isotropic Polymer Dispersed Liquid-Crystal Composite for High Contrast Ratio and Fast Response Time Seung Hee Lee, Chonbuk National University, Jeonju, Korea
- P.94: A High-Sensitivity PDLC Based Electro-Optic Modulator for TFT Array Inspection Chang-Jae Yu, Hanyang University, Seoul, Korea
- P.95: Process Technology of Flexible and Transparent Display by Stacking OLED and PDLC Embedded with OPV Jiun-Haw Lee, National Taiwan University, Taipei, Taiwan, ROC
- P.96: Synthesis of Reactive Mesogen and Its Stabilizing Characteristics in Polymer Stabilized Vertically Aligned LCD Seung Hee Lee, Chonbuk National University, Jeonju, Korea

Surface and Alignment

- **P.97:** Low Driving Voltage and Gray Scale Capability of Nanostructure Enhanced Cholesteric Liquid Crystal Device *Yi-Fan Liang, National Chiao Tung University, Hsinchu, Taiwan, ROC*
- **P.98:** Novel Composite Photo-Alignment Layer for Ferroelectric LCD *Qi Guo, Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong*
- **P.99:** Alignment Peculiarities of Cholesteric Liquid Crystals on the Surfaces Processed by Plasma Beam Oleg Yaroshchuk, Institute of Physics, National Academy of Science Ukraine, Kyiv, Ukraine
- P.100: Multi-Domain Vertical Alignment of Liquid Crystals through Control of the Anchoring Energy Tae-Hoon Yoon, Pusan National University, Busan, Korea
- P.146L:Late News Poster: Practical Approach of New Photoalignment Material for High Quality Competitive Retardation Film Gyo-jic Shin, Korea Institute of Industrial Technology (KITECH), Cheonan-do, Korea
- P.155L:Late News Poster: Surface Monolayer Stabilized Vertically Aligned Liquid Crystals for Display Applications Shin-Woong Kang, Chonbuk National University, Jeonju, Korea

Wide-Viewing

- P.101: Investigation on Flexoelectric Effect in the Fringe Field Switching Mode Seung Hee Lee, Chonbuk National University, Jeonju, Korea
 P.102: Improvement of Gamma Curve Distortion in VA LCDs by Using an Optical Film-Patterned Retarder Gi Dong Lee, Dong-A University, Busan, Korea
- P.103: High Transmittance LC Mode Based on Fringe Field Switching of Vertically Aligned Negative LC Tae-Hoon Yoon, Pusan National University, Busan, Korea
- P.104: Two Face Viewable Display Using Dye Doped Liquid Crystal Chao Ping Chen, Shanghai Jiao Tong University, Shanghai, China
- P.105: Normally Black Electrically Controlled Birefringence Mode with Slit Electrode Structure Jin Seog Gwag, Yeungnam University, Gyeonggi-do, Korea

OLEDs

- P.106: Magnetic Resonant Wireless Power Transmission to Thin OLED Lighting Panel *Yong-Hae Kim, ETRI, Daejeon, Korea* P.107: New Emissive Materials for Mixed Host Architectures to Achieve Longer Lifetime for (
- P.107: New Emissive Materials for Mixed Host Architectures to Achieve Longer Lifetime for Green-to-Red Phosphorescent OLED Displays and Lighting Application Cheng Yao, E-Ray Optoelectronics Technology Co., Ltd., Chungli, Taiwan, ROC
- P.108: Organic Wrinkles as Optical Scattering Source Jaehyun Moon, ETRI, Daejeon, Korea

P.109: Improvement of the Outcoupling Efficiency of Blue OLEDs Kyung Cheol Choi, KAIST, Daejeon, Korea P.110: High Efficiency OLEDs Based on the Gradient Doping in Transport Layer Gufeng He, Shanghai Jiao Tong University, Shanghai, China P.111: Double Hybrid Tandem White OLEDs Employing a Novel Charge Generation Unit Gufeng He, Shanghai Jiao Tong University, Shanghai, China P.112: High Efficiency Blue Phosphorescence OLED Device with Novel CbzTAZ Host Tien-Lung Chiu, Yuan Ze University, Chung-Li, Taiwan, ROC P.113: Luminous Efficiency Improvement of Photovoltaic Device Integrated OLED with Dual Function **Guiding-Mode Resonance Structure** ChiaYu Shen, National Taiwan University, Taipei, Taiwan, ROC P.114: Cl-2 Plasma Treated Indium-Tin-Oxide Electrodes with High Work Function for OLEDs Kyung Bok Choi, Korea University, Seoul, Korea P.115: Micropyramid Array with Antireflective Nanostructure Surfaces for Light Extraction Efficiency Enhancement of OLED Devices Pei-Kuen Wei, Academia Sinica, Taipei, Taiwan, ROC P.116: Light Extraction Improvement of Flexible Top Emitting OLED Devices by Using Nanoimprinted Periodically Corrugated Polycarbonate Substrate Pei-Kuen Wei, Academia Sinica, Taipei, Taiwan, ROC P.117: Orientation of fillers in CNT/Polymer Composite Interfacial Laver for Enhancing Charge Transportation Rubaiya Rahman, University of California at Berkeley, Berkeley, CA, USA P.118: Improvement of the Quantum Efficiency in OLEDs Using Stochastic Metallic Nanostructure Sangho Park, Seoul National University, Seoul, Korea P.119: Improved Performance of Polymer LEDs Using a Conjugated Polyelectrolyte and Ag Electrode Changhee Lee, Seoul National University, Seoul, Korea P.120: P-Doped Hole Transporting Layers for Improving Power Efficiency of OLEDs Changhee Lee, Seoul National University, Seoul, Korea P.121: Good Color Stable Phosphorescent White OLEDs with Double Emissive Layer Structure Jang Hyuk Kwon, Kyung Hee University, Seoul, Korea P.122: Optical Control of Surface Plasmon Loss in Transparent OLED Devices Coupled with Optical Compensation Layer Akiyoshi Mikami, Kanazawa Institutre of Technology, Nonoichi, Japan P.123: Electroluminescence Properties of WOLED with a New Yellow Fluorescent Material Dong Myung Shin, Hong-ik University, Seoul, Korea P.124: Ultra-Thin Flexible Graphene Oxide/PDDA Encapsulation Layer for OLED Displays Jin-Nam Jeon, Hong-ik University, Seoul, Korea P.125: Color Characterization Models for OLED Displays Pei-Li Sun, National Taiwan University of Science & Technology, Taipei, Taiwan, ROC P.126: New Polymerizable Liquid Crystal and Its Reverse Wavelength Dispersion Property Kei Sakamoto, ZEON Corp., Kanagawa, Japan P.138L:Late News Poster: Accurate Evaluation of Light-Extraction Efficiency for OLEDs with Light Out-Coupling Layer Hironori Wakana, Hitachi, Ltd., Tokvo, Japan P.139L:Late News Poster: The Advantage of Ambient Contrast Ratio in WRGB OLED Displays Hyun Seung Kim, LG Display Co., Ltd., Gyeonggi-do, Korea P.140L:Late News Poster: Highly Efficient Inverted OLED with Air Stable Electron Injection Layer Hirohiko Fukagawa, NHK Science and Technology Research Laboratory, Tokyo, Japan P.141L:Late News Poster: ALD Based Multilayer Encapsulation of PIN OLED: On the Stability of the Organic Layer in 85°C / 85%RH Storage Conditions Tony Maindron, CEA-LETI, Grenoble, France P.142L:Late News Poster: Electron Injecting Material for OLEDs Driven by Oxide TFTs: Amorphous C12A7 Electride Satoru Watanabe, Asahi Glass Co., Ltd., Yokohama, Japan P.143L:Late News Poster: Light Extraction in OLEDs Using SF₆/CHF₃ Plasma Treated Random Pattern Byeong-Kwon Ju, Korea University, Seoul, Korea P.144L:Late News Poster: Synthesis and Electroluminescence Properties of Highly Efficient Blue Fluorescent Emitters Using a Dual-Core Chromophore Jongwook Park, Catholic University of Korea, Bucheon, Korea P.145L:Late News Poster: Synthesis and Device Application of Carboline Derivatives as High Triplet Energy Materials for **Blue Phosphorescent OLEDs** Jun Yeob Lee, Dankook University, Yongin, Korea P.151L:Late-News Poster: Multi-Scale Modeling of OLED Devices Stephane Altazin, Fluxim AG, Feusisberg, Switzerland **Projection** P.127: 55-in. 3D Short Throw Rear Projection System with Broadband Polarizing Type Glasses Sheng Hao Chen, National Taiwan University, Taipei, Taiwan, ROC

Touch and Interactivity

P.128:	Virtual Force-Sensing Using Smooth Stroke Reconstruction Algorithm for Capacitive Touch Panel
	Chih-Lung Lin, National Cheng Kung University, Tainan, Taiwan, ROC

- **P.129:** A Simple and Effective Way to Improve Projected-Capacitive Touch Panel Architecture *Tsz-Kin Ho, Hong Kong University of Science and Technology, Clear Water Bay, Hong Kong*
- P.130: A Measurement Based Time and Frequency Domain Analysis of LCD VCOM Noise Dong-Hee Yeo, LG Display Co., Ltd., Pohang, Korea
- P.131: A Signicant Multi-Touch Algorithm for the Tracking Problem Based on the Hungarian Algorithm Shih-Lun Huang, National Taiwan University, Taipei, Taiwan, ROC
- P.132: Enhancing the Visual Performance of Touch Screen Displays Timothy Robinson, Esterline Control System Korry, Everett, WA, USA
- P.133: 3D Multi-Touch System by Using Coded Optical Barrier on Embedded Photo-Sensor Toshiki Kaneko, Japan Display, Inc., Mobara, Japan

P.153L:Late News Poster: An Interactive Application of Instant Haptic Feedback Sheng-Po Wang, ITRI, Chutung, Taiwan, ROC